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Determining the Richardson constant of Ni/4H-SiC and W/4H-SiC Schottky diodes via Current-Voltage-Temperature (IVT) characteristics

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Abstract content
 (Max 300 words)
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In this project the Richardson constant (A) for metal-semiconductor contacts on 4H-SiC was investigated by means of current-voltage measurements as a function of temperature in the range of 300 K to 700 K. Multiple n-type 4H-SiC-based metal-semiconductor contacts, having an estimated carrier concentration of $3.70 \times 10^{14} \text{ cm}^{-3}$ were considered. The current-voltage-temperature (IVT) characteristics of Ni/4H-SiC and W/4H-SiC Schottky barrier diodes were studied, based on the thermionic emission model. The samples were prepared using various deposition techniques, (viz. Ni – resistive evaporation and electron-beam deposition (EBD); and W – RF sputtering and EBD) and diode parameters (such as ideality factor (η), Schottky barrier height (Φ_B), series resistance (R_s) and saturation current (I_s)) obtained were compared and found to be strongly dependent on temperature. The Richardson constant for 4H-SiC obtained from the intercept of a least squares fit through the Arrhenius plot data resulted in $3.72 \times 10^{-6} \text{ A.K}^{-2} \text{ cm}^{-2}$ for W and $5.41 \text{ A.K}^{-2} \text{ cm}^{-2}$ for Ni – both deposited via EBD; $2.63 \times 10^{-3} \text{ A.K}^{-2} \text{ cm}^{-2}$ for Ni deposited resistively, and lastly $6.31 \times 10^{-12} \text{ A.K}^{-2} \text{ cm}^{-2}$ for sputtered W. It was concluded that A is dependent on the metal contact as well as the type of deposition technique utilized for the Schottky metal contacts.

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Level for award (Hons, MSc, PhD)?

Hons

Main supervisor (name and email) and his / her institution

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**Would you like to
 submit a short paper
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 Proceedings (Yes / No)?**

No

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